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**W-8000 München 80 (DE)**(54) **Variable contrast X-ray material.**

(57) Disclosed is a silver halide photographic light-sensitive material comprising a support and an first emulsion layer (the HS layer) having a first maximum density on one side of a support and an second emulsion layer (the LS layer) on the other side of a support having a said second maximum density which second maximum density is lower than first maximum density, wherein the HS layer has a maximum density of 1.80 or more, when exposure is performed on the HS layer such that the density of the HS layer after processing is a fogging density + 1.10, the density of the LS layer is a fogging density + 0.20 or low, and when exposure is performed on the HS layer, the gradient of a straight line connecting a fogging density + 0.5 and a fogging density + 1.3 in the characteristics curve for the HS layer is within the range of 1.50 to 2.90; and when exposure is performed from the LS layer, the gradient of a straight line connecting a fogging density + 0.3 and a fogging density + 0.6 in the characteristic curve for the LS layer is not less than 1.10, and the sensitivity of the HS layer ( $S_H$ ) is lower than that of the LS layer ( $S_L$ ) wherein each of  $S_H$  and  $S_L$  is the reciprocal of an amount of exposure needed to obtain a density represented by the following

formula:

$$[(\text{Maximum density} - \text{fogging density}) \times 0.4] + \text{fogging density}.$$

A silver halide photographic light-sensitive material according to this invention is capable of providing a highly-sensitive silver halide photographic material for X-ray photography.

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## EUROPEAN SEARCH REPORT

Application Number

EP 92 11 2724

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.5)
X	EP-A-0 384 633 (KODAK) * the whole document * ---	1-12	G03C1/46 G03C5/17
P,X	EP-A-0 440 367 (KONICA) * the whole document * -----	1-12	
			TECHNICAL FIELDS SEARCHED (Int. Cl.5)
			G03C
The present search report has been drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 28 APRIL 1993	Examiner MAGRIZOS S.
<b>CATEGORY OF CITED DOCUMENTS</b> X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons ..... & : member of the same patent family, corresponding document			